

small methods

Supporting Information

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On the Elusive Crystallography of Lithium-Rich Layered Oxides: Novel Structural Models

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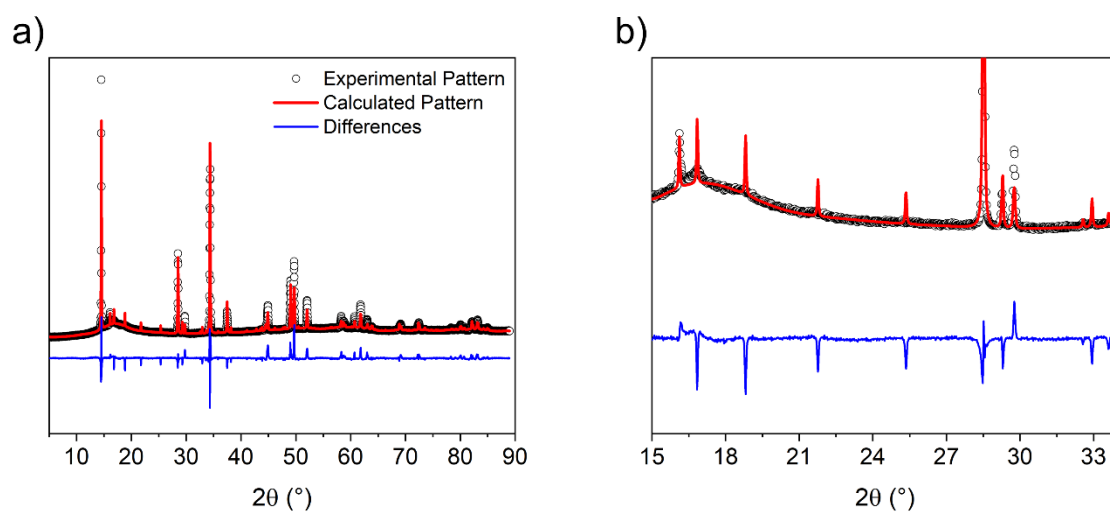


Figure S1: a) Rietveld refinement using two phases model, rhombohedral and monoclinic.

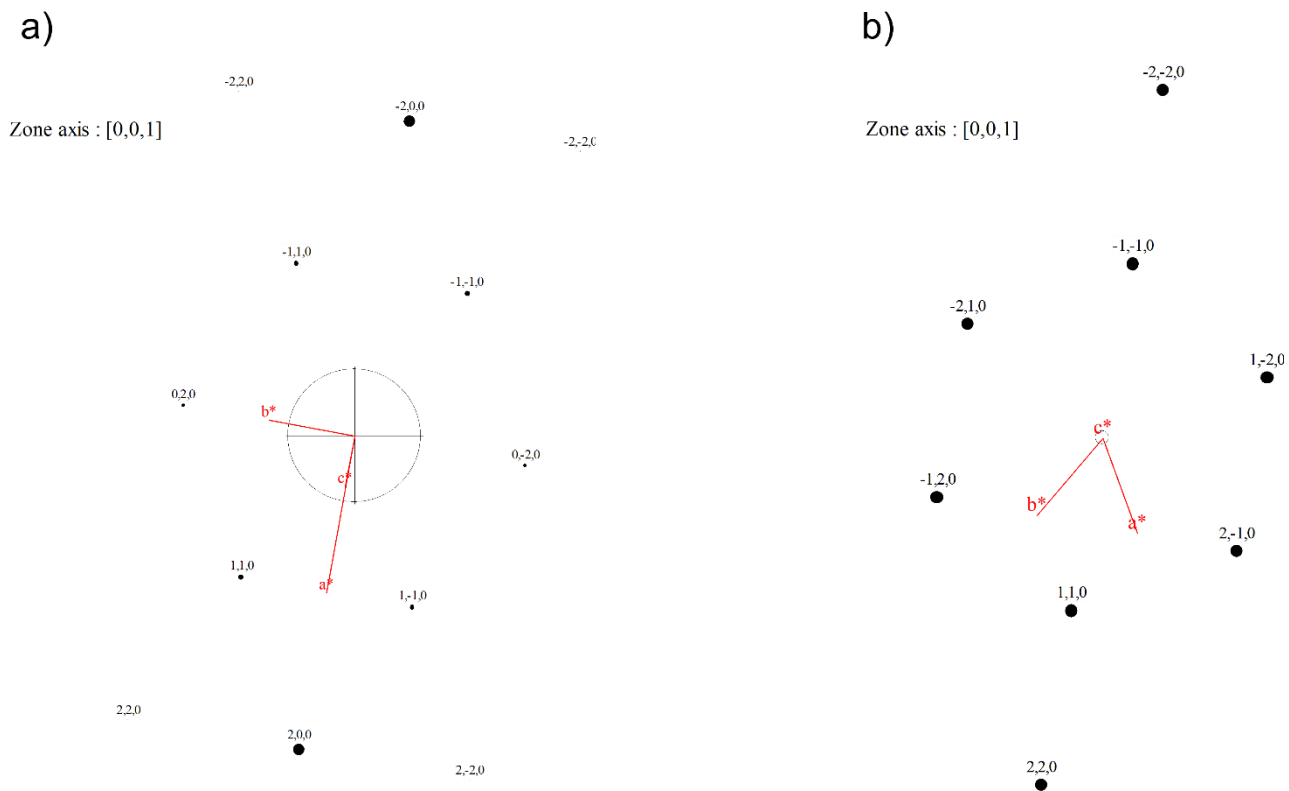


Figure S2: Single-crystal ED pattern calculated for the $[001]$ axis zone for a) $C2/m$ and b) $R-3m$ (with lattice parameters a and b 3 times larger).

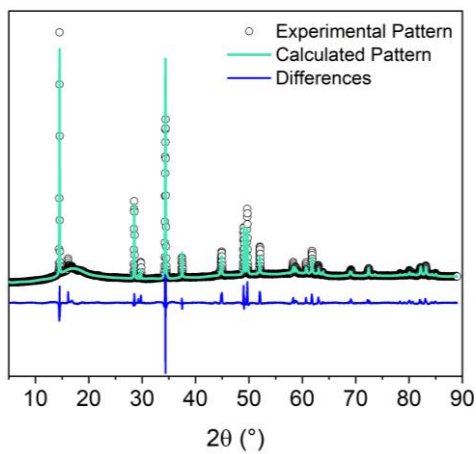


Figure S3: a) Rietveld refinement using $R-3m$ with anti-site and oxygen defects.

| Table S1: Rietveld refined parameters for R-3m with anti-site and oxygen defects. | |
|--|--|
| Space group | R-3m (R=4.9%; Z=99) |
| Lattice parameters | a=b=2.855 c=14.247 $\alpha=\beta=90^\circ \gamma=120^\circ$ |
| Atomic position and occupancies (Wyckoff position; OF=occupancy fraction) | |
| Lithium ion layer | (3b) (0 0 ½) OF(Li)=0.981 OF(TM)=0.019 |
| Metal ions blend layer | (3a) (0 0 0) OF(Li)=0.299 OF(TM)=0.701 |
| Oxygen ions layers | (6c) (0 0 0.746) OF=0.97 |

| Table S2: Rietveld refined parameters for C2/M with 2b-4g site mixing. | |
|--|---|
| Space group | C 2/m (R=4%; Z=83) |
| Lattice parameters | a=4.947 b=8.563 c=5.032 $\alpha=\gamma=90^\circ \beta=109.3^\circ$ |
| Atomic position and occupancies (Wyckoff position; OF=occupancy fraction) | |
| Lithium ion layer | (2c) (0 0 ½) OF(Li)=1 |
| | (4h) (0 0.685 ½) OF(Li)=1 |
| Metal ions blend layer | (2b) (0 ½ 0) OF(Li)=0.466 OF(TM)=0.534 |
| | (4g) (0 0.169 0) OF(Li)=0.187 OF(TM)=0.813 |
| Oxygen ions layers | (4i) (0.252 0 0.231) OF(O)=1 |
| | (8j) (0.25 0.327 0.245) OF(O)=1 |

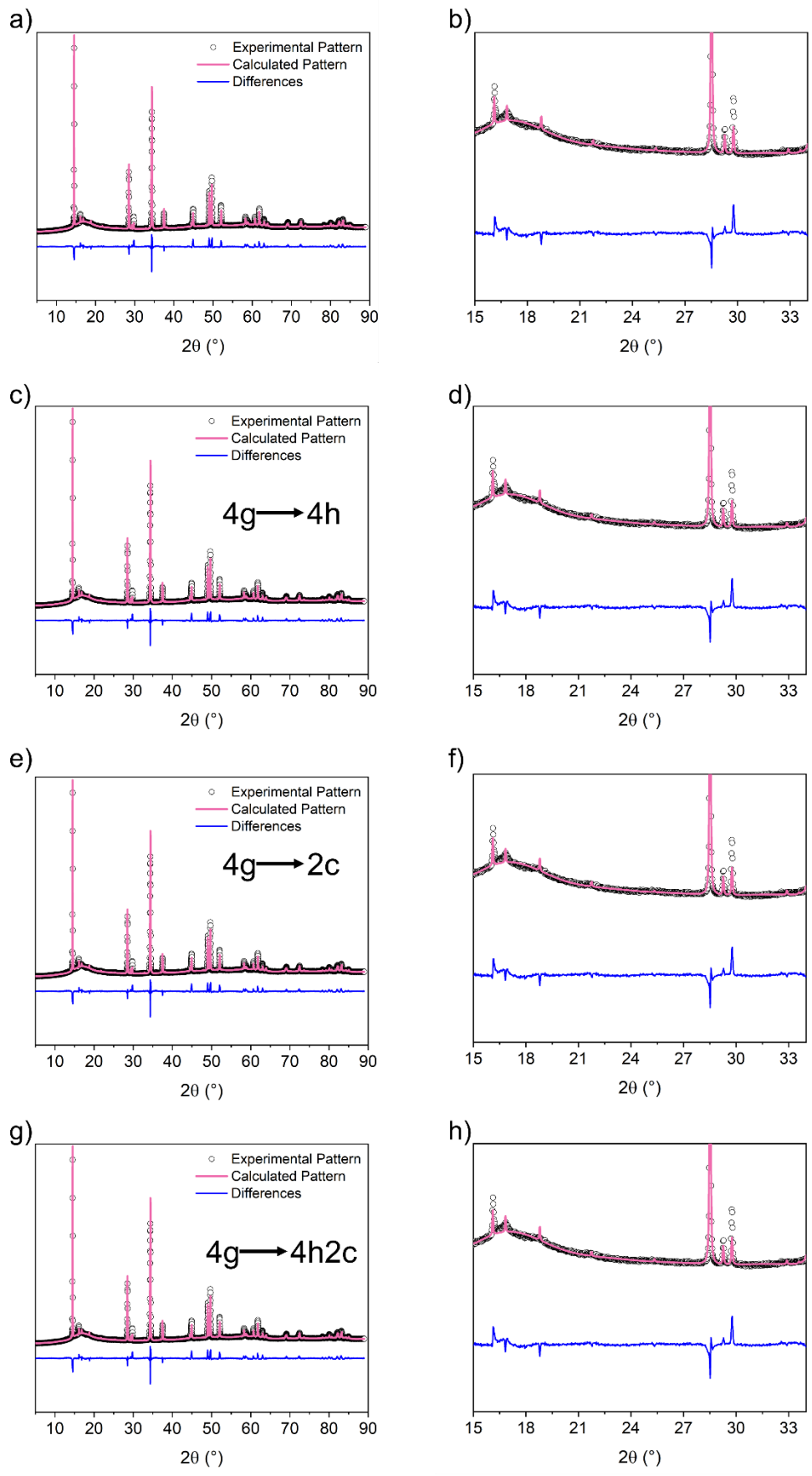


Figure S4: Rietveld refinement using C2/m with a-b) Li-TM mixing in TM layers, c-d) 4g-4h, e-f) 4g-2c and g-h) 4g-4h2c anti-site defects.

Table S3: Rietveld refined parameters for C2/M with different anti-site defects.

| Space group | 4g-4h (R=3.99%; Z=83) | 4g-4h2c (R=3.98%; Z=83) | 4g-2c (R=3.97%; Z=83) |
|---|---|---|---|
| Lattice parameters | a=4.947 b=8.563 c=5.032 $\alpha=\gamma=90^\circ \beta=109.3^\circ$ | a=4.947 b=8.563 c=5.032 $\alpha=\gamma=90^\circ \beta=109.3^\circ$ | a=4.947 b=8.563 c=5.032 $\alpha=\gamma=90^\circ \beta=109.3^\circ$ |
| Atomic position and occupancies (Wycoff position; OF=occupancy fraction) | | | |
| Lithium ion layer | (2c) (0 0 ½) OF(Li)=1 | (2c) (0 0 ½) OF(Li)=0.9970 OF(Mn)=0.0030 | (2c) (0 0 ½) OF(Li)=0.9899 OF(Mn)=0.0101 |
| | (4h) (0 0.688 ½) OF(Li)=0.9989 OF(Mn)=0.0011 | (4h) (0 0.686 ½) OF(Li)=0.9985 OF(Mn)=0.0015 | (4h) (0 0.687 ½) OF(Li)=1 |
| Metal ions blend layer | (2b) (0 ½ 0) OF(Li)=0.466 OF(Mn)=0.534 | (2b) (0 ½ 0) OF(Li)=0.466 OF(Mn)=0.534 | (2b) (0 ½ 0) OF(Li)=0.460 OF(Mn)=0.540 |
| | (4g) (0 0.169 0) OF(Mn)=0.812 OF(Li)=0.188 | (4g) (0 0.168 0) OF(Mn)=0.811 OF(Li)=0.188 | (4g) (0 0.169 0) OF(Mn)=0.808 OF(Li)=0.192 |
| Oxygen ions layers | (4i) (0.252 0 0.231) OF (O) = 1 | (4i) (0.252 0 0.231) OF (O) = 1 | (4i) (0.254 0 0.232) OF (O) = 1 |
| | (8j) (0.25 0.327 0.246) OF (O) = 1 | (8j) (0.25 0.327 0.245) OF (O) = 1 | (8j) (0.249 0.326 0.245) OF (O) = 1 |

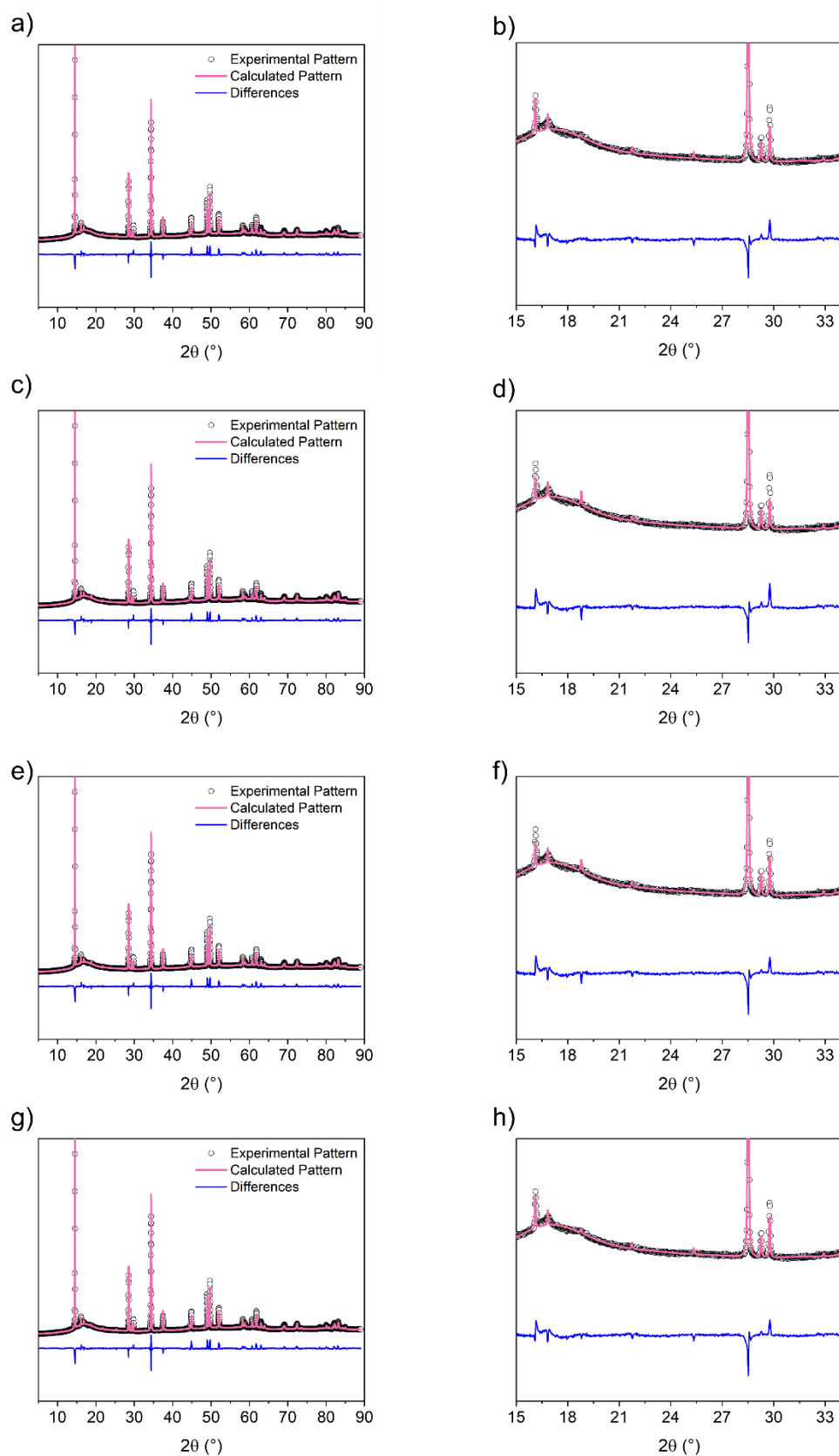


Figure S5: Calculated patterns vs experimental pattern using C2/M with anti-site defects and oxygen vacancies. a-b) oxygen vacancies in 4i site, c-d) oxygen vacancies in 8j site, e-f) oxygen vacancies in 4i and 8j sites with a constrain in the atomic fraction and g-h) oxygen vacancies in 4i and 8j sites.

| Table S4: Rietveld refined parameters for C2/M with anti-site defects and oxygen vacancies. | | | | |
|--|--|--|--|--|
| Space group | 8j (R=3.97%; Z=77) | 4i8j equal fraction (R=3.95%; Z=76) | 4i8j (R=3.93%; Z=73) | 4i (R=3.94%; ; Z=73) |
| Lattice parameters | a=4.947 b=8.563 c=5.032 $\alpha=\gamma=90^\circ \beta=109.3^\circ$ | a=4.947 b=8.563 c=5.032 $\alpha=\gamma=90^\circ \beta=109.3^\circ$ | a=4.947 b=8.563 c=5.032 $\alpha=\gamma=90^\circ \beta=109.3^\circ$ | a=4.947 b=8.563 c=5.032 $\alpha=\gamma=90^\circ \beta=109.3^\circ$ |
| Atomic position and occupancies (Wyckoff position; OF=occupancy fraction) | | | | |
| Lithium ion layer | (2c) (0 0 ½) OF(Li)=0.9899 OF(Mn)=0.0101 | (2c) (0 0 ½) OF(Li)=0.9899 OF(Mn)=0.0101 | (2c) (0 0 ½) OF(Li)=0.9899 OF(Mn)=0.0101 | (2c) (0 0 ½) OF(Li)=0.9899 OF(Mn)=0.0101 |
| | (4h) (0 0.685 ½) OF(Li)=1 | (4h) (0 0.685 ½) OF(Li)=1 | (4h) (0 0.685 ½) OF(Li)=1 | (4h) (0 0.682 ½) OF(Li)=1 |
| Metal ions blend layer | (2b) (0 ½ 0) OF(Li)=0.466 OF(TM)=0.534 | (2b) (0 ½ 0) OF(Li)=0.466 OF(TM)=0.534 | (2b) (0 ½ 0) OF(Li)=0.466 OF(TM)=0.534 | (2b) (0 ½ 0) OF(Li)=0.460 OF(Mn)=0.540 |
| | (4g) (0 0.169 0) OF(Li)=0.187 OF(TM)=0.813 | (4g) (0 0.169 0) OF(Li)=0.187 OF(TM)=0.813 | (4g) (0 0.169 0) OF(Li)=0.187 OF(TM)=0.813 | (4g) (0 0.169 0) OF(Mn)=0.808 OF(Li)=0.192 |
| Oxygen ions layers | (4i) (0.252 0 0.232) OF (O) = 1 | (4i) (0.253 0 0.235) OF (O) = 0.9324 | (4i) (0.253 0 0.235) OF (O) = 0.8441 | (4i) (0.252 0 0.234) OF (O) = 0.8503 |
| | (8j) (0.25 0.326 0.245) OF (O) = 0.9659 | (8j) (0.249 0.327 0.244) OF (O) = 0.9324 | (8j) (0.249 0.327 0.244) OF (O) = 0.9722 | (8j) (0.249 0.326 0.245) OF (O) = 1 |

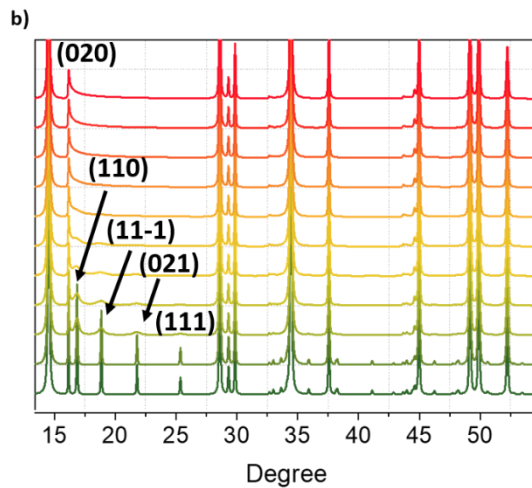
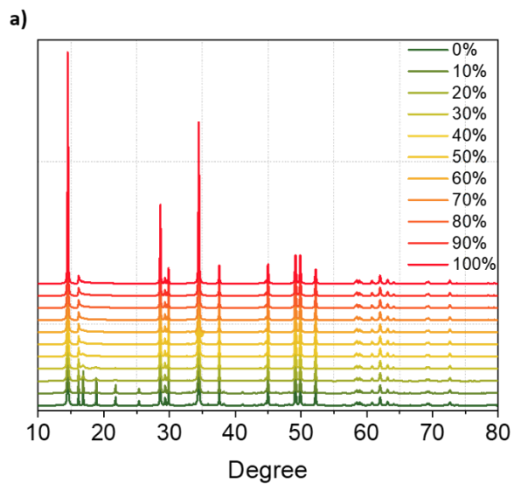


Figure S6: a) DIFFaX simulated XRD patterns with varying stacking fault probabilities. b) Enlarged view in the superstructure region.

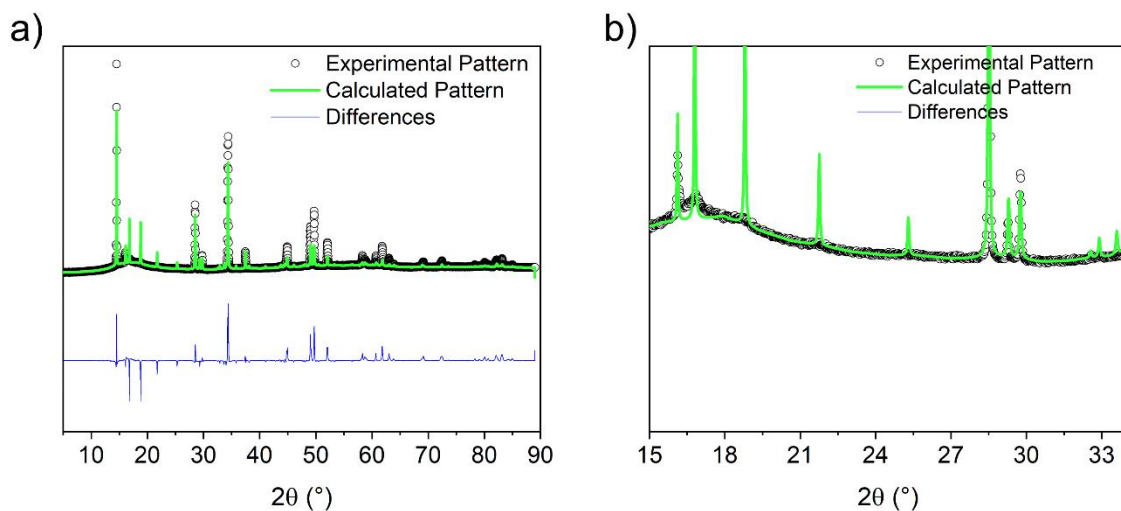


Figure S7: a) FAULTS refinement pattern without stacking faults. R-factor=8.4% and Z=95.

| Table S5: Values from the FAULTS refinement without stacking faults. | | | | | |
|---|-------------|--------------|------------|--------------|------------------|
| Unit cell parameters | | | | | |
| a, b (Å) | | c (Å) | | γ (°) | |
| 4.939 | | 4.743 | | 60.09 | |
| Layer compositions | | | | | |
| Layer | Atom | x/a | y/b | z/c | Occupancy |
| L1 | Li | 0 | 0 | 0 | 1 |
| | Li | 1/3 | 1/3 | 0 | 1 |
| | Li | 2/3 | 2/3 | 0 | 1 |
| L2=L3=L4 | Li | 0 | 0 | 0 | 0.84 |
| | TM | 0 | 0 | 0 | 0.16 |
| | TM | 0.334 | 0.334 | 0 | 1 |
| | TM | 0.663 | 0.663 | 0 | 1 |
| | O | 0.354 | -0.0089 | 0.249 | 1 |
| | O | 0.643 | 0.0063 | -0.246 | 1 |
| | O | -0.0092 | 0.354 | -0.246 | 1 |
| | O | 0.337 | 0.660 | -0.225 | 1 |
| | O | 0.660 | 0.337 | 0.242 | 1 |
| O | 0.0064 | 0.644 | 0.248 | 1 | |

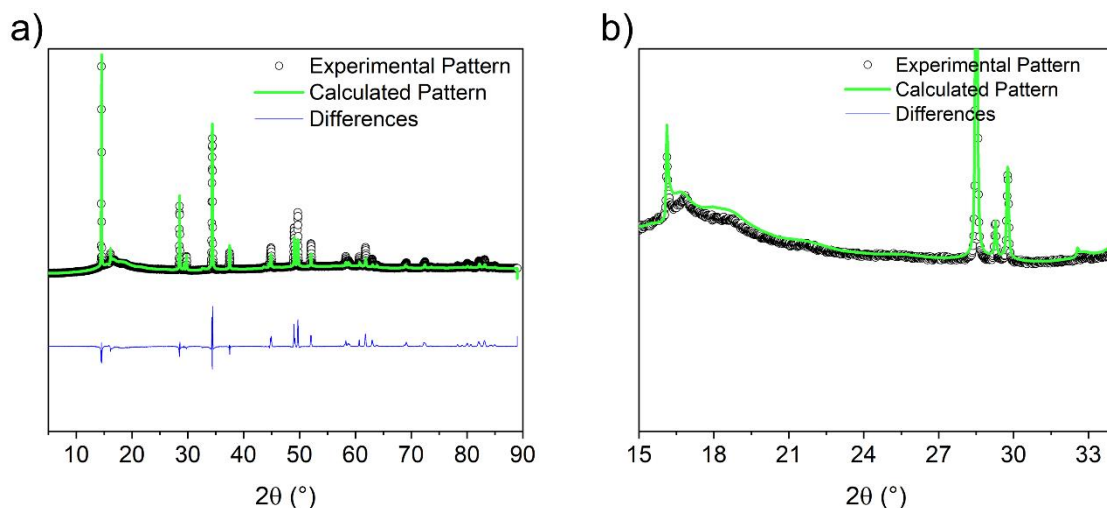


Figure S8: a) FAULTS refinement pattern. Magnified view of the refined data in the 15–25° 2 θ range. R-factor=6.7% and Z=90.

Table S6: Values from the FAULTS refinement with staking faults (around 48%).

| Unit cell parameters | | | | | |
|----------------------|-------|---------|---------|--------------|-----------|
| a, b (Å) | | c (Å) | | γ (°) | |
| 4.939 | | 4.743 | | 60.09 | |
| Layer compositions | | | | | |
| Layer | Atom | x/a | y/b | z/c | Occupancy |
| L1 | Li | 0 | 0 | 0 | 1 |
| | Li | 1/3 | 1/3 | 0 | 1 |
| | Li | 2/3 | 2/3 | 0 | 1 |
| L2=L3=L4 | Li | 0 | 0 | 0 | 0.84 |
| | TM | 0 | 0 | 0 | 0.16 |
| | TM | 0.337 | 0.337 | 0 | 1 |
| | Li | 0.337 | 0.337 | 0 | 1 |
| | TM | 0.662 | 0.662 | 0 | 1 |
| | Li | 0.662 | 0.662 | 0 | 1 |
| | O | 0.355 | -0.0055 | 0.252 | 1 |
| | O | 0.644 | 0.0023 | -0.251 | 1 |
| | O | -0.0021 | 0.360 | -0.252 | 1 |
| | O | 0.331 | 0.667 | -0.244 | 1 |
| | O | 0.668 | 0.330 | 0.245 | 1 |
| O | 0.020 | 0.636 | 0.253 | 1 | |

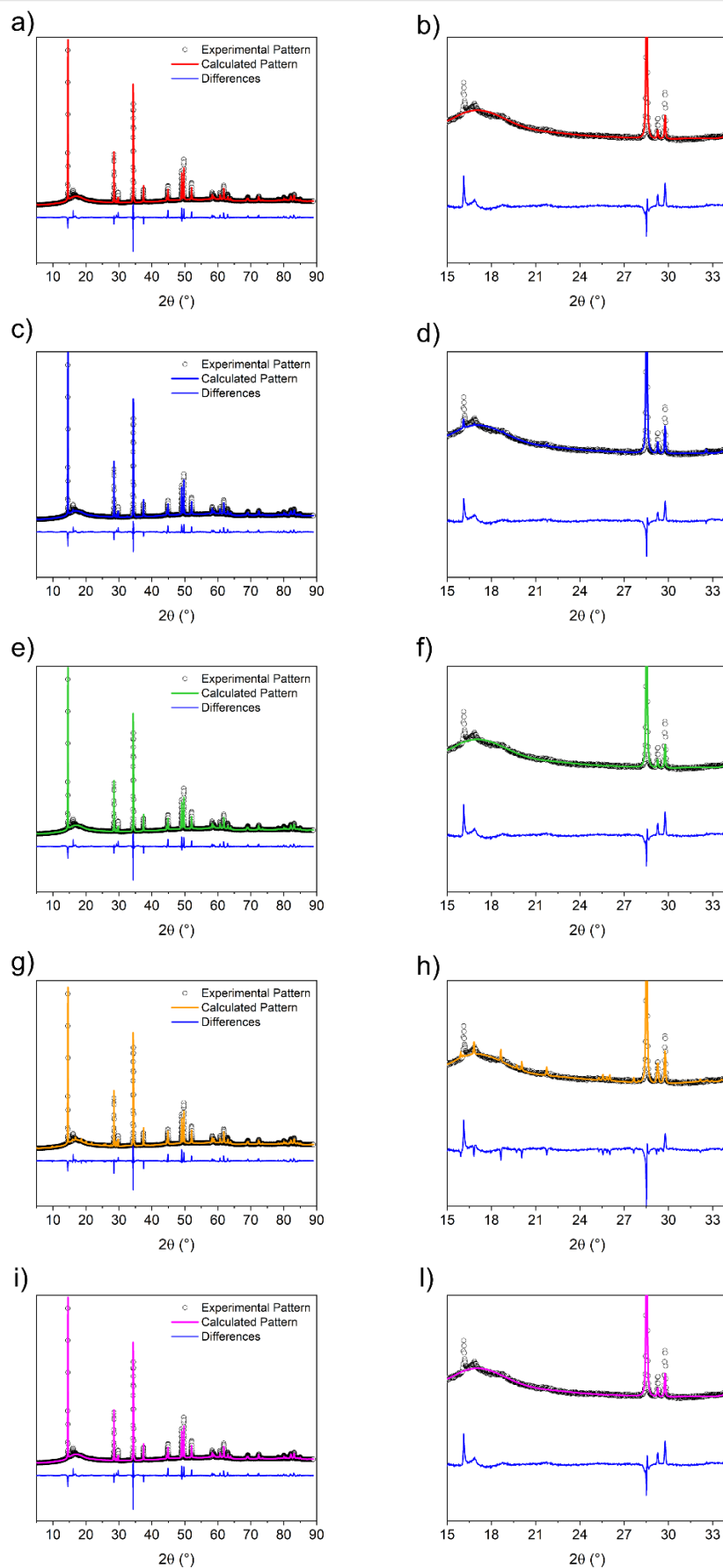


Figure S9: Comparison of Rietveld refinements results using a-b) RC_3a, c-d) RC_3b, e-f) RC_3c, g-h) RC_3a_3b and i-l) RC_3a_b_ac unit cell.

Table S7: Rietveld refined parameters for supercells.

| | R_C_3a | R_C_3b | R_C_3c | R_C_3a_3b | R_C_3a_b_ac |
|---|--|--|--|---|--|
| Lithium ion layer | (2d) (0 ½ ½) OF(Li)=1 | (2d) (0 ½ ½) OF(Li)=1 | (2d) (0 ½ ½) OF(Li)=1 | (2d) (0 ½ ½) OF(Li)=1 | (2c) (0 0 ½) OF(Li)=1 |
| | (4i) (0.833 0 0.5) OF(Li)=1 | (4h) (0 0.825 0.5) OF(Li)=1 | (4i) (0.5 0 0.845) OF(Li)=1 | (4h) (0 0.823 ½) OF(Li)=1 | (4i) (0.667 0 0.5) OF(Li)=1 |
| | | | | (4i) (0.166 0 0.479) OF(Li)=1 | |
| (8j) (0.833 0.328 0.49) OF(Li)=1 | | | | | |
| Metal ions blend layer | (2a) (0 0 0) OF(Li)=0.28 OF(TM)=0.72 | (2a) (0 0 0) OF(Li)=0.28 OF(TM)=0.72 | (2a) (0 0 0) OF(Li)=0.28 OF(TM)=0.72 | (2a) (0 0 0) OF(Li)=0.28 OF(TM)=0.72 | (2a) (0 0 0) OF(Li)=0.28 OF(TM)=0.72 |
| | (4i) (0.666 0 -0.006) OF(Li)=0.28 OF(TM)=0.72 | (4g) (0 0.669 0) OF(Li)=0.28 OF(TM)=0.72 | (4i) (0.004 0 0.668) OF(Li)=0.28 OF(TM)=0.72 | (4g) (0 0.66 0) OF(Li)=0.28 OF(TM)=0.72 | (4i) (0.67 0 -0.003) OF(Li)=0.28 OF(TM)=0.72 |
| | | | | (4i) (0.331 0 -0.014) OF(Li)=0.28 OF(TM)=0.72 | |
| (4i) (0.665 0.337 0.007) OF(Li)=0.28 OF(TM)=0.72 | | | | | |
| Oxygen ions layers | (4i) (0.914 0 0.266) OF(O)=1 | (4i) (0.708 0 0.217) OF(O)=1 | (4i) (0.752 0 0.747) OF(O)=1 | (4i) (0.085 0 0.739) OF(O)=1 | (4i) (0.826 0 0.266) OF(O)=1 |
| | (4i) (0.585 0 0.256) OF(O)=1 (4i) (0.248 0 0.266) OF(O)=1 | (8j) (0.244 0.319 0.726) OF(O)=1 | (4i) (0.746 0 0.43) OF(O)=1 | (8j) (0.919 0.37 0.294) OF(O)=1 | (4i) (0.504 0 0.232) OF(O)=1 |
| | | | (4i) (0.734 0 0.08) OF(O)=1 | (4i) (0.419 0 0.773) OF(O)=1 | (4i) (0.156 0 0.277) OF(O)=1 |
| | | | | (8j) (0.583 0.339 0.307) OF(O)=1 | |
| | | | | (4i) (0.754 0 0.768) OF(O)=1 | |
| (8j) (0.251 0.345 0.282) OF(O)=1 | | | | | |

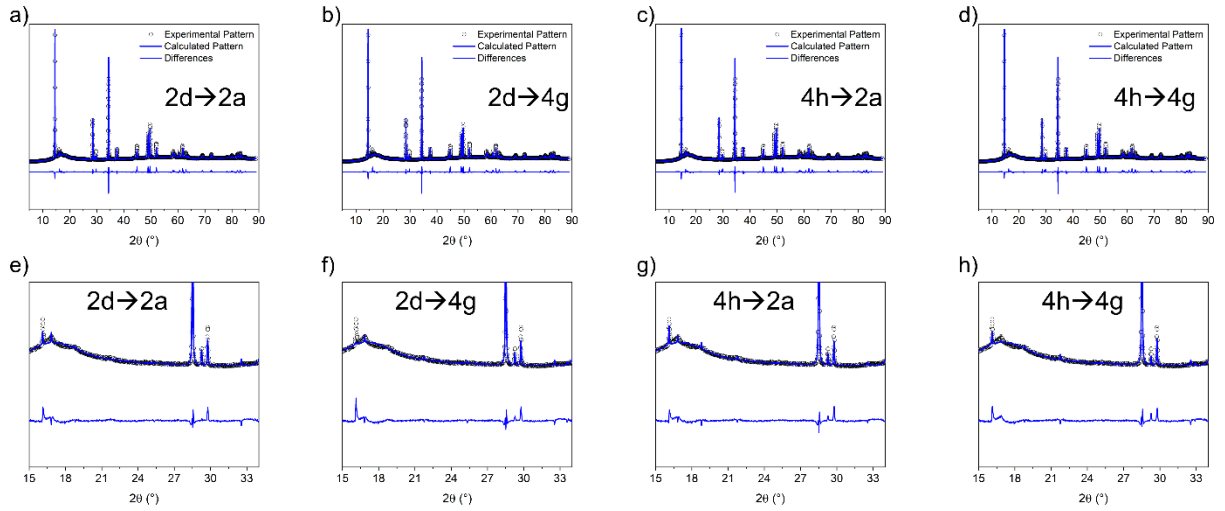


Figure S10: Calculated patterns vs experimental pattern using RC_3b with anti-site defects.

Table S8: Rietveld refined parameters for RC_3b with antisite defects.

| | 2d2a (Z=79) | 4h4g (Z=79) | 2d4g (Z=79) | 4h2a (Z=79) |
|-------------------------------|--|---|--|--|
| Lithium ion layer | (2d) (0 ½ ½) OF(Li)=0.9195 OF(TM)=0.0805 | (2d) (0 ½ ½) OF(Li)=1 | (2d) (0 ½ ½) OF(Li)=0.927 OF(TM)=0.073 | (2d) (0 ½ ½) OF(Li)=1 |
| | (4h) (0 0.814 0.5) OF(Li)=1 | (4h) (0 0.823 0.5) OF(Li)=0.959 OF(Ni)=0.0410 | (4h) (0 0.825 0.5) OF(Li)=1 | (4h) (0 0.815 0.5) OF(Li)=0.967 OF(Ni)=0.033 |
| Metal ions blend layer | (2a) (0 0 0) OF(Li)=0.3605 OF(TM)=0.6395 | (2a) (0 0 0) OF(Li)=0.28 OF(TM)=0.72 | (2a) (0 0 0) OF(Li)=0.28 OF(TM)=0.72 | (2a) (0 0 0) OF(Li)=0.346 OF(TM)=0.654 |
| | (4g) (0 0.667 0) OF(Li)=0.28 OF(TM)=0.72 | (4g) (0 0.668 0) OF(Li)=0.321 OF(TM)=0.679 | (4g) (0 0.668 0) OF(Li)=0.3165 OF(TM)=0.6835 | (4g) (0 0.667 0) OF(Li)=0.28 OF(TM)=0.72 |
| Oxygen ions layers | (4i) (0.746 0 0.273) OF(O)=1 | (4i) (0.728 0 0.237) OF(O)=1 | (4i) (0.732 0 0.252) OF(O)=1 | (4i) (0.732 0 0.251) OF(O)=1 |
| | (8j) (0.246 0.314 0.741) OF(O)=1 | (8j) (0.236 0.316 0.721) OF(O)=1 | (8j) (0.237 0.319 0.728) OF(O)=1 | (8j) (0.239 0.319 0.730) OF(O)=1 |

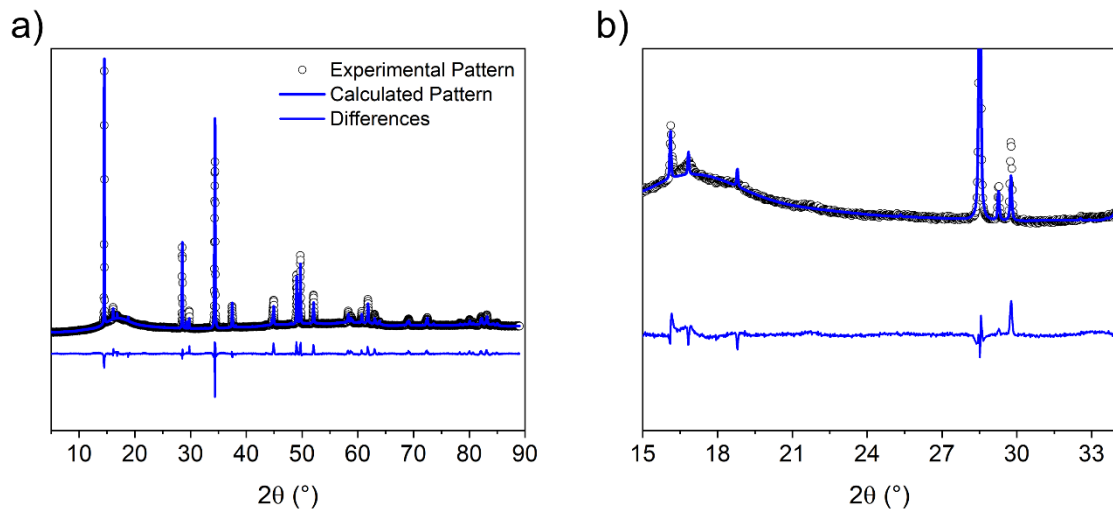


Figure S11: Calculated patterns vs experimental pattern using RC_3b with anti-site defects and Li-TM mixing (4g-2a).

| Table S9: Rietveld refined parameters for RC_3b with Li-TM mixing and 4h2a anti site defects. | |
|--|---|
| | 2d2a ((Z=76) |
| Lithium ion layer | (2d) (0 ½ ½) OF(Li)=0.9195 OF(TM)=0.0805 |
| | (4h) (0 0.814 0.5) OF(Li)=1 |
| Metal ions blend layer | (2a) (0 0 0) OF(Li)=0.3645 OF(TM)=0.5714 |
| | (4g) (0 0.667 0) OF(Li)=0.2377 OF(TM)=0.7623 |
| Oxygen ions layers | (4i) (0.746 0 0.273) OF(O)=1 |
| | (8j) (0.246 0.314 0.741) OF(O)=1 |

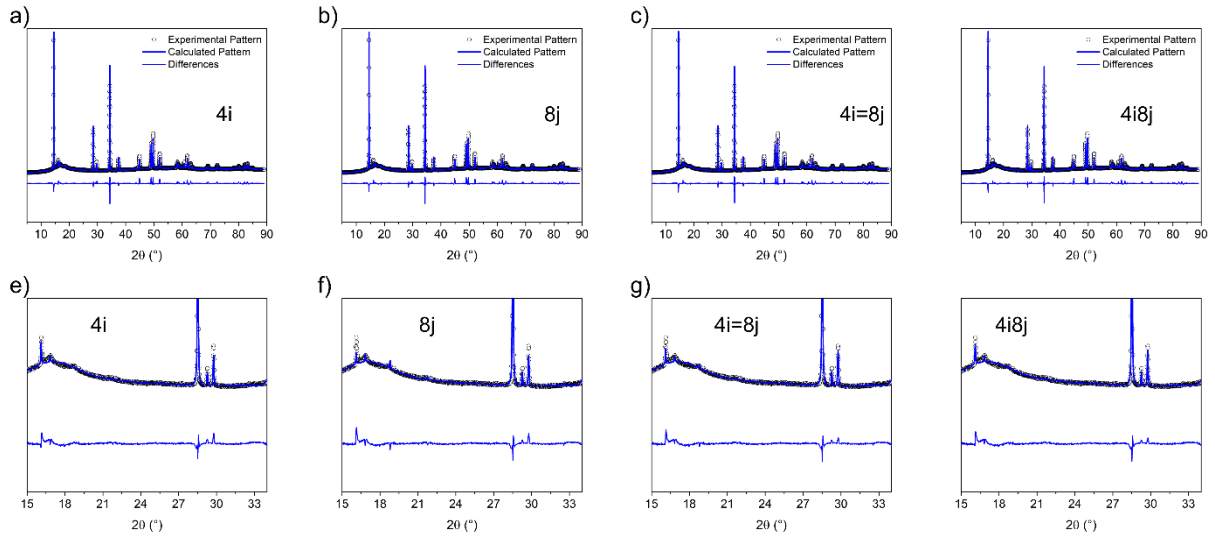


Figure S12: Calculated patterns vs experimental pattern using RC_3b with oxygen vacancies.

Table S10: Rietveld refined parameters for RC_3b with oxygen vacancies.

| | 4i (Z=73) | 8j (Z=72) | 4i=8j (Z=70) | 4i8j (Z=70) |
|-------------------------------|--|--|--|--|
| Lithium ion layer | (2d) (0 ½ ½) OF(Li)=0.9195 OF(TM)=0.0805 | (2d) (0 ½ ½) OF(Li)=0.9195 OF(TM)=0.0805 | (2d) (0 ½ ½) OF(Li)=0.9195 OF(TM)=0.0805 | (2d) (0 ½ ½) OF(Li)=0.9195 OF(TM)=0.0805 |
| | (4h) (0 0.814 0.5) OF(Li)=1 | (4h) (0 0.814 0.5) OF(Li)=1 | (4h) (0 0.814 0.5) OF(Li)=1 | (4h) (0 0.814 0.5) OF(Li)=1 |
| Metal ions blend layer | (2a) (0 0 0) OF(Li)=0.3645 OF(TM)=0.5714 | (2a) (0 0 0) OF(Li)=0.3645 OF(TM)=0.5714 | (2a) (0 0 0) OF(Li)=0.3645 OF(TM)=0.5714 | (2a) (0 0 0) OF(Li)=0.3645 OF(TM)=0.5714 |
| | (4g) (0 0.667 0) OF(Li)=0.2377 OF(TM)=0.7623 | (4g) (0 0.667 0) OF(Li)=0.2377 OF(TM)=0.7623 | (4g) (0 0.667 0) OF(Li)=0.2377 OF(TM)=0.7623 | (4g) (0 0.667 0) OF(Li)=0.2377 OF(TM)=0.7623 |
| Oxygen ions layers | (4i) (0.732 0 0.245) OF(O)=0.8661 | (4i) (0.732 0 0.247) OF(O)=1 | (4i) (0.732 0 0.243) OF(O)=0.9259 | (4i) (0.733 0 0.242) OF(O)=0.8661 |
| | (8j) (0.241 0.322 0.730) OF(O)=1 | (8j) (0.239 0.321 0.730) OF(O)=0.9341 | (8j) (0.240 0.321 0.723) OF(O)=0.9259 | (8j) (0.242 0.322 0.730) OF(O)=0.9513 |

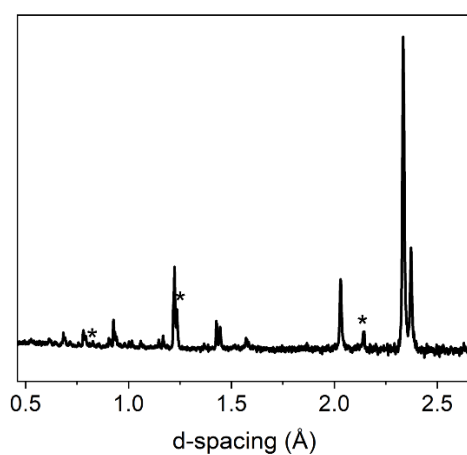


Figure S13: Neutron Diffraction data of $\text{Li}_{1.28}\text{Mn}_{0.54}\text{Ni}_{0.13}\text{Co}_{0.02}\text{Al}_{0.03}\text{O}_2$ from bank 5 detector.

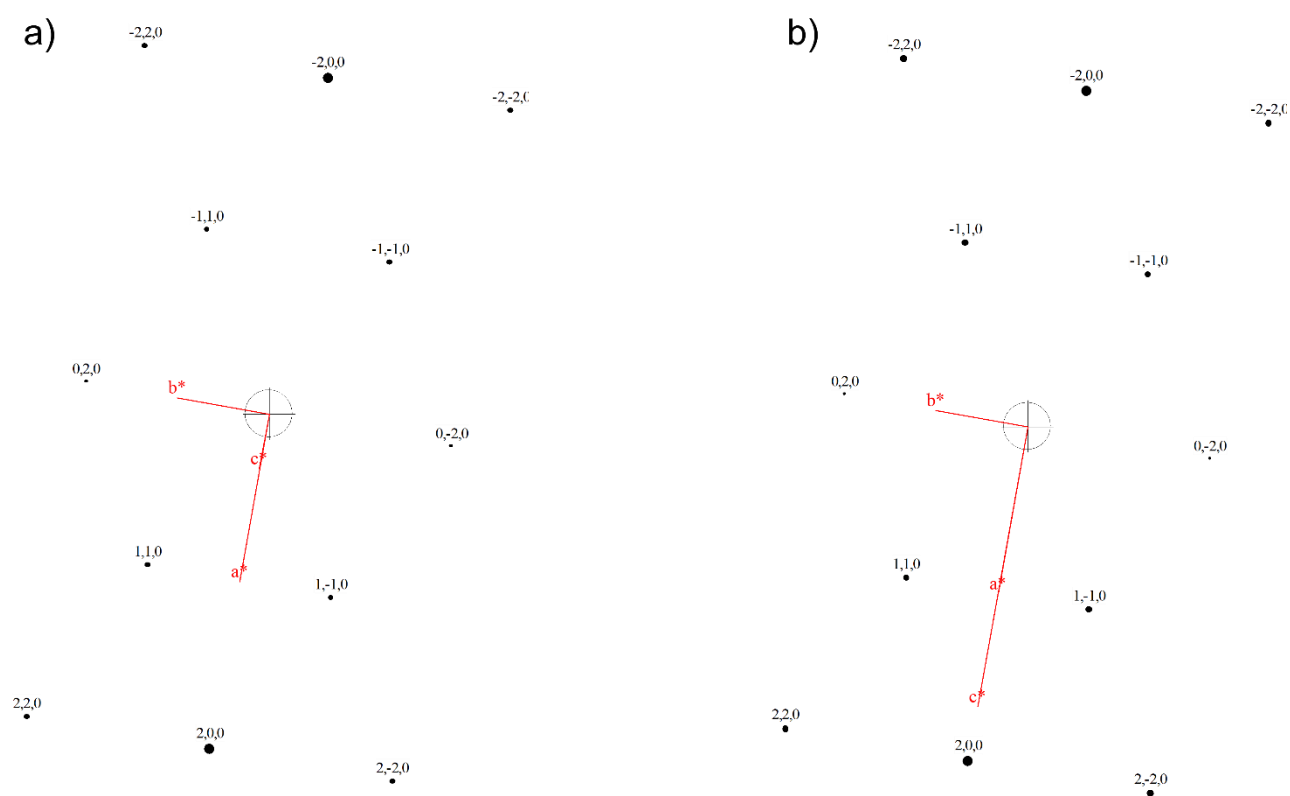


Figure S14: Single-crystal ED pattern along the $[001]$ axis zone for a) M_{def} and b) SC_{def} .

Table S11: Rietveld refined lattice parameters obtained from Neutron Diffraction pattern.

| | a (Å) | b (Å) | c (Å) | β (°) |
|-------------------------------------|--------------|--------------|--------------|-------------------------------|
| M_{def} | 4.938 | 8.555 | 5.022 | 109.24 |
| SC_{def} | 9.625 | 8.553 | 5.022 | 151.01 |